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CONFIRMATION NO. 1715

<b>SERIAL NUMBER</b> 10/529,044	<b>FILING or 371(c) DATE</b> 01/17/2006 <b>RULE</b>	<b>CLASS</b> 360	<b>GROUP ART UNIT</b> 1794	<b>ATTORNEY DOCKET NO.</b> 0001.1045		
<b>APPLICANTS</b> Joo-Ho Kim, Youngin-si, KOREA, REPUBLIC OF; Junji Tominaga, Ibaraki, JAPAN; <b>** CONTINUING DATA *****</b> This application is a 371 of PCT/KR03/01949 09/24/2003 <b>** FOREIGN APPLICATIONS *****</b> JAPAN 2002-281783 09/26/2002 <b>** IF REQUIRED, FOREIGN FILING LICENSE GRANTED **</b>						
Foreign Priority claimed <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No 35 USC 119(a-d) conditions met <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No Verified and Acknowledged <u>/KEVIN M. BERNATZ/</u> Examiner's Signature		<input type="checkbox"/> Met after Allowance Initials	<b>STATE OR COUNTRY</b> KOREA, REPUBLIC OF	<b>SHEETS DRAWINGS</b> 4	<b>TOTAL CLAIMS</b> 10	<b>INDEPENDENT CLAIMS</b> 2
<b>ADDRESS</b> STEIN, MCEWEN & BUI, LLP 1400 EYE STREET, NW SUITE 300 WASHINGTON, DC 20005 UNITED STATES						
<b>TITLE</b> High density recording medium with super-resolution near-field structure manufactured using high-melting point metal oxide or silicon oxide mask layer						
<b>FILING FEE RECEIVED</b> 1030	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:		<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees (Filing) <input type="checkbox"/> 1.17 Fees (Processing Ext. of time) <input type="checkbox"/> 1.18 Fees (Issue) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit			